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PATENT

41935

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of :
Akiko HEMMI et al. : Group Art Unit: 1751
Serial No.: 09/887,345 : Examiner: B. Mruk
Filed: June 25, 2001 :
For: LOW-MOLECULAR (METH)ACRYLIC :
ACID (SALT)-BASED POLYMER AND ITS :
PRODUCTION PROCESS AND USES :

RECEIVED
JUL 09 2003
TC 1700

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In accordance with 37 C.F.R. § 1.97 and § 1.98, Applicants bring the disclosures attached and listed on completed Form PTO-1449 to the Examiner's attention and request that they be considered and made of record in this application.

The enclosed patents were cited in Applicants' corresponding Chinese application, and a copy of a Notice on Office Action from the Chinese Patent Office dated April 11, 2003, and English translation thereof, is enclosed.

CN 1251846 corresponds to U.S. Patent Application Pub. No. US 2002/0035224 A1, and CN 1053925 corresponds to U.S. Patent No. 5,055,540.

Since the enclosed patents were cited by the Chinese Patent Office not more than three months prior to the submission of this Information Disclosure Statement, it is believed that no fee is required for consideration of these patents. However, the Examiner is hereby

authorized to charge any fees which may become due in connection with this communication or credit any overpayment to Deposit Account No. 18-2220.

Respectfully submitted,


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